

Tungsten Disilicide (WSi2) Sputtering Targets

Material Type	Tungsten Silicide	Theoretical Density (g/cc)	9.4
Symbol	WSi2	Z Ratio	**1.00
Melting Point (°C)	>900	Sputter	RF
Purity:	99.99%, 99.95%	Type of Bond	Indium